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CRYSTALLIZATIONS OF AMORPHOUS Y-Ba-Cu-O FILM PREPARED BY RF-SPUTTERING

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Amorphous $YBa_2Cu_3O_Y$ itself and $YBa_2Cu_3O_Y$ Abstract containing F excess amount orCuO films were prepared by rf-sputtering. Film texture such preferred orientation and superconductivity investigated on these films crystallized in oxygen at various temperatures. Substrate also studied on MgO (100) and SrTiO3 rf-power (110)in relation to applied sputter deposition. The addition of foreign elements were effective to lowering crystallization temperature on MgO substrate. preferred orientations of YBCO on SrTiO3 changed with the deposition conditions of amorphous film.

INTRODUCTION

Superconducting thin film can be obtained sputtering on high temperature substrate (≈ 700 °C) asdeposited. Deposition on low temperature amorphous film, where we can homogeneously foreign elements because of the wide compositional of amorphous state. Its film texture can controlled by changing the crystallization conditions. have investigated crystallizations of amorphous Al2031 and barium ferrite2 films. Addition of fluoride YBa2Cu3Oy have been studied, but its role is ambiguous3.

EXPERIMENTAL

Y-Ba-Cu-O thin film was prepared Amorphous by rfsputtering using YBa3.45Cu3.50Ov sintered target Addition of F performed by putting $(\phi 80 \times 5 mm)$. small targets (\$10x1mm) containing YF3, BaF2 and CuO on above-mentioned large target. Sputter gas mixture of $Ar/O_2 = 1$ and the pressure was 1.8Pa. The deposition rate was 0.35~0.55 \u03b2m/h. Substrates MgO and SrTiO3 single crystals. Crystallization in O2 flow at desired temperatures. emission analysis showed the chemical composition of films without additives were very to YBa2Cu3Ov.

RESULTS and DISCUSSION

Amorphous films with 0.8µm thickness on MgO annealed in a temperature range of Ta = $920 \sim 1020$ °C4. crystallized but preferred orientation was clear in Ta < 950°C. Remarkable preferred orientation perpendicular to substrate was of YBCO <001> 970°C accompanying a pronounced > Amorphous film with fluoride on MgO can be crystallized to a mixture of YBa2Cu3Oy and BaF2 700°C in oxygen flow for 2hrs. The BaF2 was observed on the films heated above 800°C for Fluoride addition enhanced grain growth and orientation of YBa2Cu3Ov platy crystal. The film with F heated at 920°C had a strongly preferred orientation YBa2Cu3Oy crystal. YBa 2Cu 3O_V crystals preferred oriented in the film with F heated at as in the film without F heated at shows X-ray diffractions of fluoride films heated in oxygen flow at 920°C for

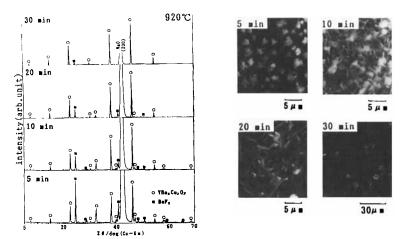


Fig. 1 X-ray diffraction and surface texture of F added YBa₂Cu₃O_y films/MgO with oxygen annealing in various durations.

The film crystallized to a mixture durations. of and BaF2 in 5 min heating. The YBa2Cu3O_V amount of decreased and c-axis preferred orientation with increasing heat duration. observation showed that the YBCO platy crystals the amount of flower-like BaF2 crystals an increasing heat duration. EPMA investigation a fluoride amount in the annealed decreased with an increase of heating temperature and fluoride was not detected on the films above 800°C for 2hrs. μ-AES observation of the F added = 920°C showed that some observation with Ta points had different compositions from the shown in Fig. 2. Part 1 in the figure gave same spectrum as the bulk one. The part 2 was rich region and showed a presence of C probably due BaCO3. The part 3 was Cu rich region.

Superconducting Tc(onset) was in a range between 80 and 83 K as in the value of the film without

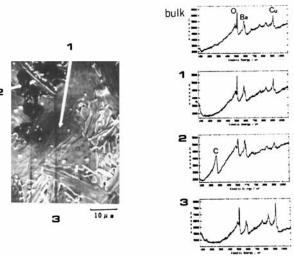


Fig. 2 SEM and micro auger electron spectrums of F added YBa₂Cu₃O_y film /MgO.

fluoride. However its Tc(zero) was low around probably because of a slight reaction with substrate. to keep fluoride in the film after treatment, the amorphous film/MgO was sealed in ampoule with anhydrous FeF3 and heated in a temperature range of 700°C to 1050°C. XRD show that the product contaminated with MgF2 and that YBa2Cu3Ov did crystallize. Crystalline YBa2Cu3Ov was observed on the samples after a further heat-treated treatment at 920°C for 2hrs. YBCO crystallizes, therefore, as the crystals without fluoride in their composition.

Crystalline orientation on SrTiO3 substrate was strongly affected by epitaxy. YBa2Cu3Oy preferentially oriented its <100> along SrTiO3 <100>, and its <110> along SrTiO3 <110> in crystallization at 900°C of the amorphous film without F. Unknown product was observed at an interface between the substrate and the film annealed above 900°C. The substrate temperature was affected by applied rf power and target composition as shown in Table 1. The films as deposited were all in

amorphous state. They were annealed in oxygen temperature range of 880 ~ 900°C. YBCO in a crystal orientation changed with the deposition tions of the amorphous film. The film deposited Ts=260°C did not show any crystal orientation after its crystallization. Epitaxial crystalline orientation of YBCO crystal with SrTiO3 substrate was observed in the deposited from the normal target at rf and also the film deposited from the added target at rf power = 100W after their annealing. Preferred orientation of YBCO (001) plane parallel substrates was observed on the film deposited from with F at rf power = 200W. It is YBa₂Cu₃O_y crystal orientation depends deposition condition of the amorphous film.

rf power	Normal target	Fluoride added target
100 W	Ts=260℃	Ts=300℃
	no orientation	YBCO<100>/SrTiO3<100>
150 ¥		Ts=360℃
		YBCO<001>,<100>/SrTiO3<100>
200 W	Ts=360℃	Ts=420℃
	YBCO<100>/SrTiO3<100>	YBC0<001>/SrTi0.<100>

Table 1. Preferred orientaof YBCO tions thin film/SrTiO3(100) relations to kinds target and strate temperatures heated bу sputtering (Ta=880 ~ 900°C).

REFERENCES

- K. Nobugai and F. Kanamaru, <u>Nihon-kagaku-kaishi</u>, 2242 (1987).
- F. Kanamaru, K. Oda, T. Yoshio and K. Takahashi, <u>Mat.</u> <u>Res.</u> <u>Bull.</u>, <u>15</u>, 525 (1980).
- S. R. Ovshinsky, R. T. Young, D. D. Allred, G. DeMaggio and G. A. Van der Leeden, <u>Phy. Rev. Lett.</u>, <u>58</u>, 2579 (1987).
- N. Moriyama, S. Kikkawa, M. Takahashi, K. Nobugai and F. Kanamaru, <u>J. Jpn. Soc. Powder & Powder</u> Metallurgy, 36, 579 (1989).